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- 54 Solvent for dry cleaning.
- Disclosed is a solvent for dry cleaning, comprising propylene glycol monomethyl ether and a solvent for dry cleaning, further containing water.



EUROPEAN SEARCH REPORT

EP 91 11 6518

	DUCUMEN 15 CONSI	DERED TO BE RELEVA	AIN I	
Category	Citation of document with i of relevant pa	ndication, where appropriate, assages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
X	WPIL, accession no.	London, GB; DATABASE 87-288557, week 201977 (TOYO INK MFG	1,2	D 06 L 1/02 C 11 D 7/50
X	163 (C-424)(2610),	JAPAN vol. 11, no. 26 May 1987; & JP - CO LTD) 24.12.1986	1	
A	US-A-3 701 627 (W.	GRUNEWALDER)	1	
A	FR-A-1 544 834 (J. * examples 2,19; cl	R. GEIGY S.A.) aims 1-4,10,12,13 *	1	
1	JOURNAL OF RADIATION CURING vol. 15, no. 2, April 1988, pages 3-7; M.R. ADAMCHUK et al.: "Propylene-Based Glycol Ethers and Acetates as		1	
	Substitutes for Met	hylene Chloride in		TECHNICAL FIELDS SEARCHED (Int. Cl.5)
	Solvent Application	5		D 06 L C 11 D
	The present search report has b	een drawn up for all claims		
	Place of search	Date of completion of the search		Examiner
BE	RLIN	17-08-1992	PELL	I-WABLAT B
CATEGORY OF CITED DOCUMENTS X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background O: non-written disclosure P: intermediate document		E : earlier pater after the fili other D : document ci L : document ci	T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons &: member of the same patent family, corresponding	